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(54) **PARTIAL BLOCK ERASE FOR A THREE DIMENSIONAL (3D) MEMORY**

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13, 2014, now Pat. No. 9,036,428.

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(52) **U.S. Cl.**

CPC **G11C 16/14** (2013.01); **G11C 16/0483**
(2013.01)

(57) **ABSTRACT**

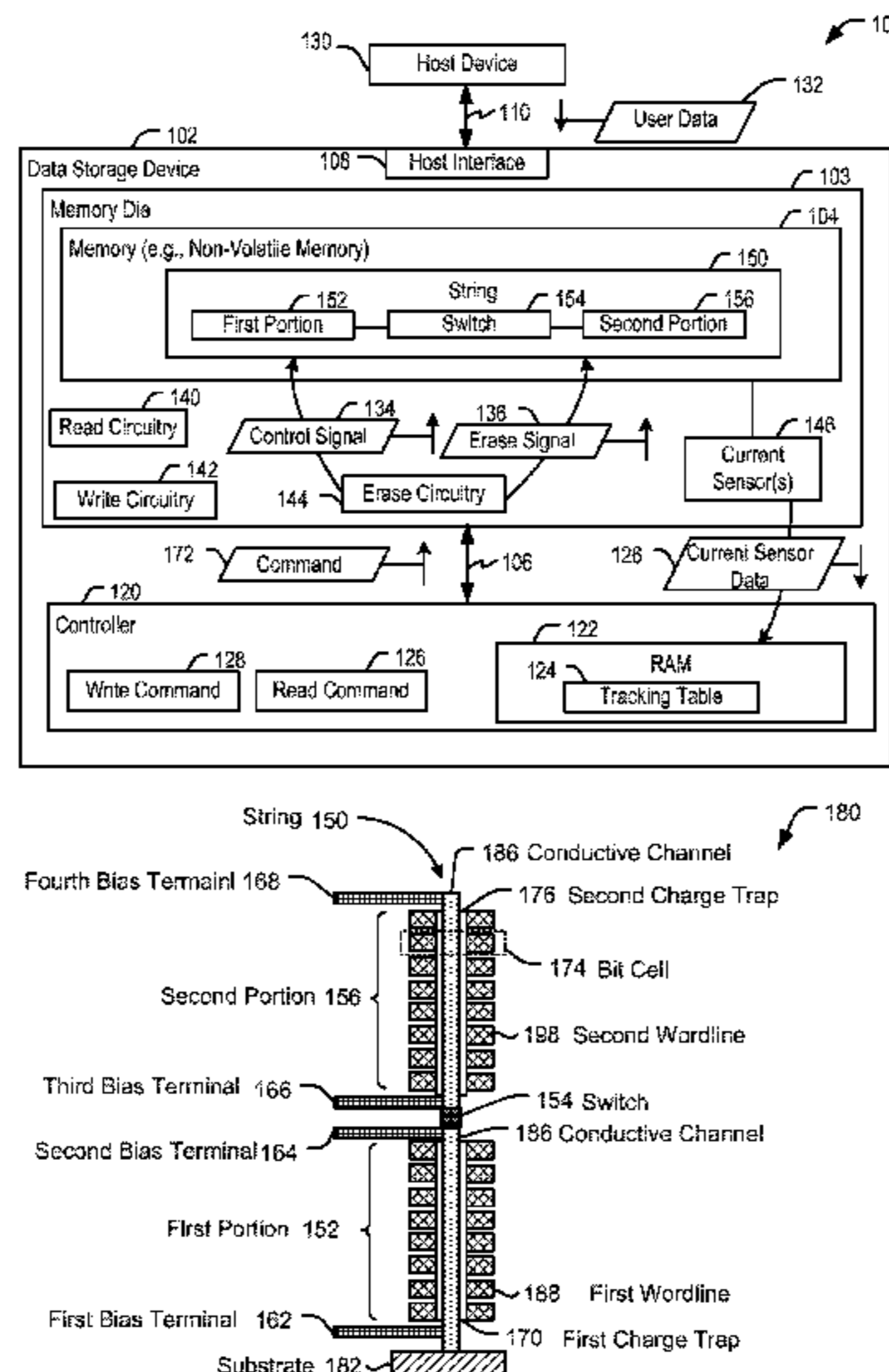
A method includes, at a non-volatile memory having a three
dimensional (3D) memory configuration, performing an
erase operation. Performing the erase operation includes pro-
viding a first control signal to isolate a first portion of a string
of the non-volatile memory from a second portion of the
string. Performing the erase operation further includes pro-
viding a first erase signal to erase the second portion of the
string while data is maintained at the first portion of the string.

(58) **Field of Classification Search**

CPC G11C 16/0483; G11C 16/10; G11C 16/26;
G11C 16/08; G11C 16/16; G11C 16/24;
G11C 7/00; G11C 8/08

See application file for complete search history.

20 Claims, 6 Drawing Sheets



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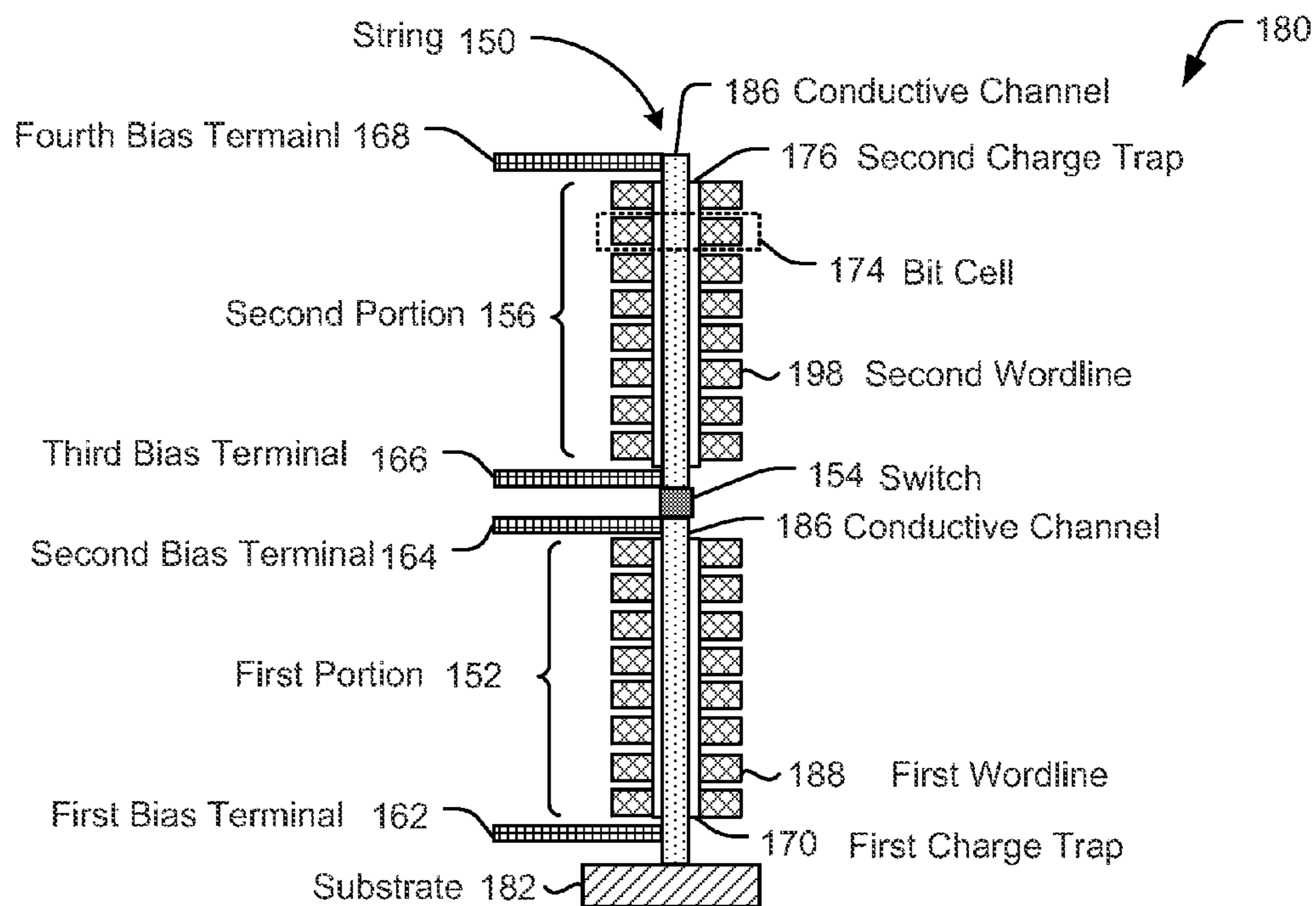
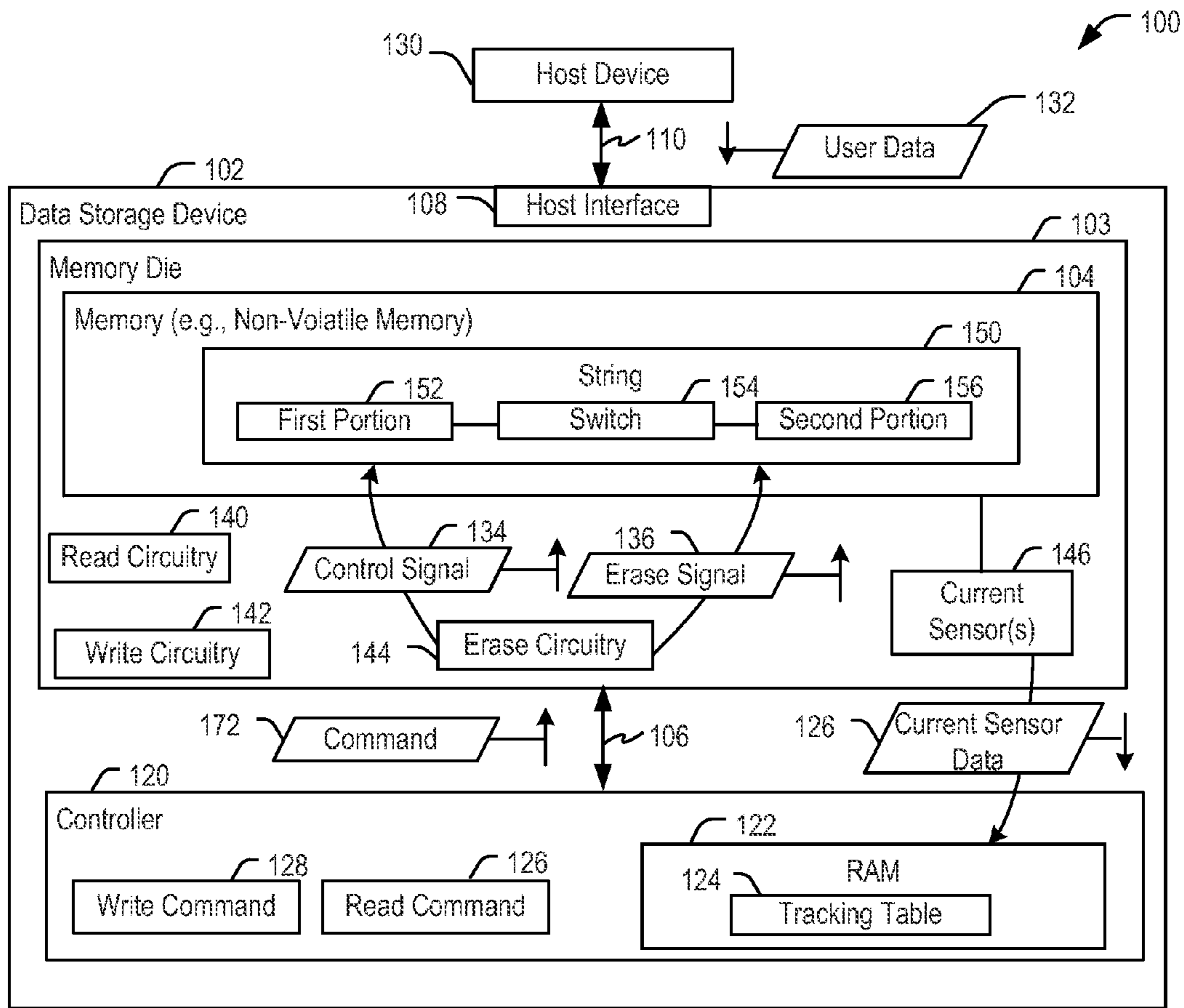


FIG. 1

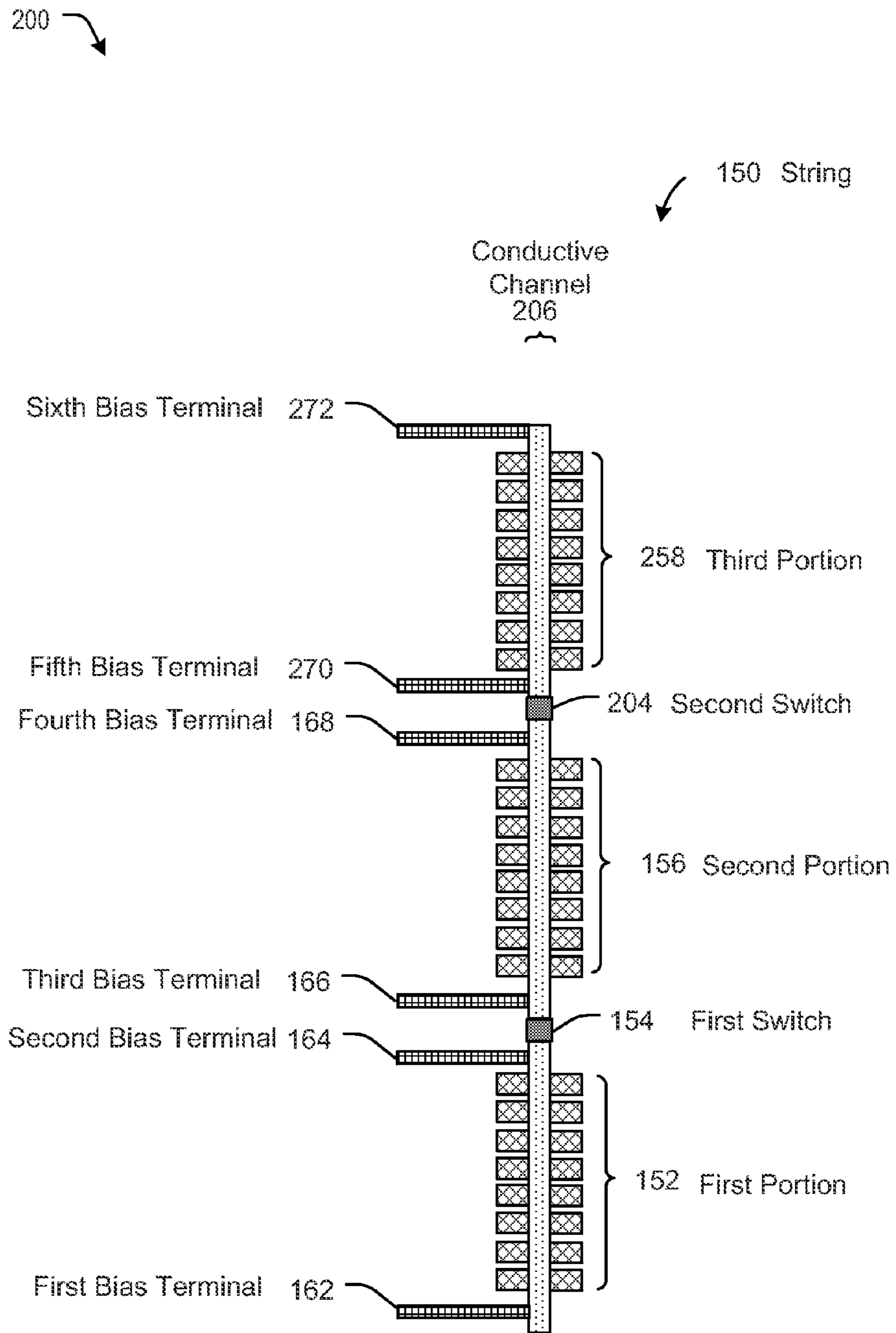


FIG. 2

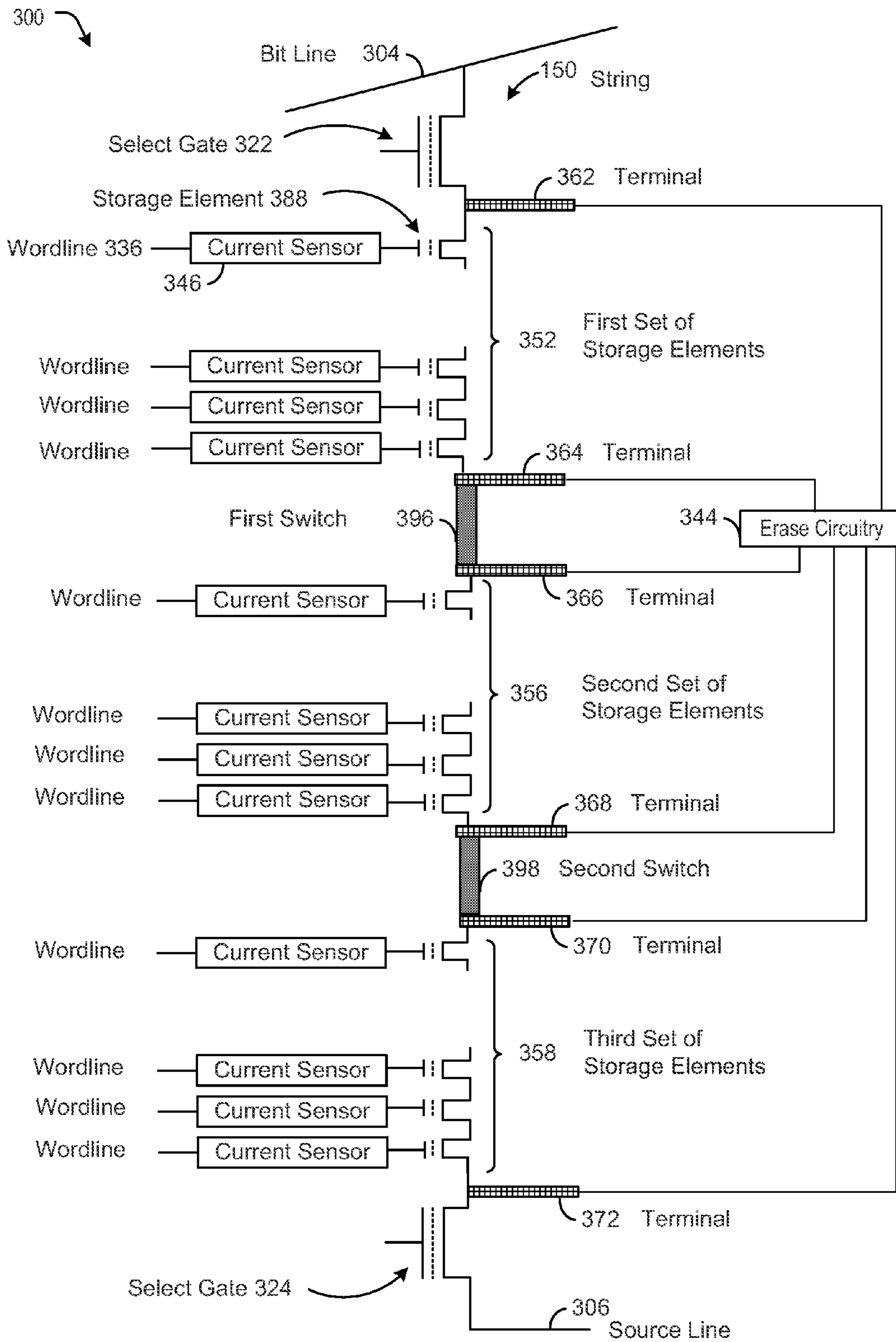


FIG. 3

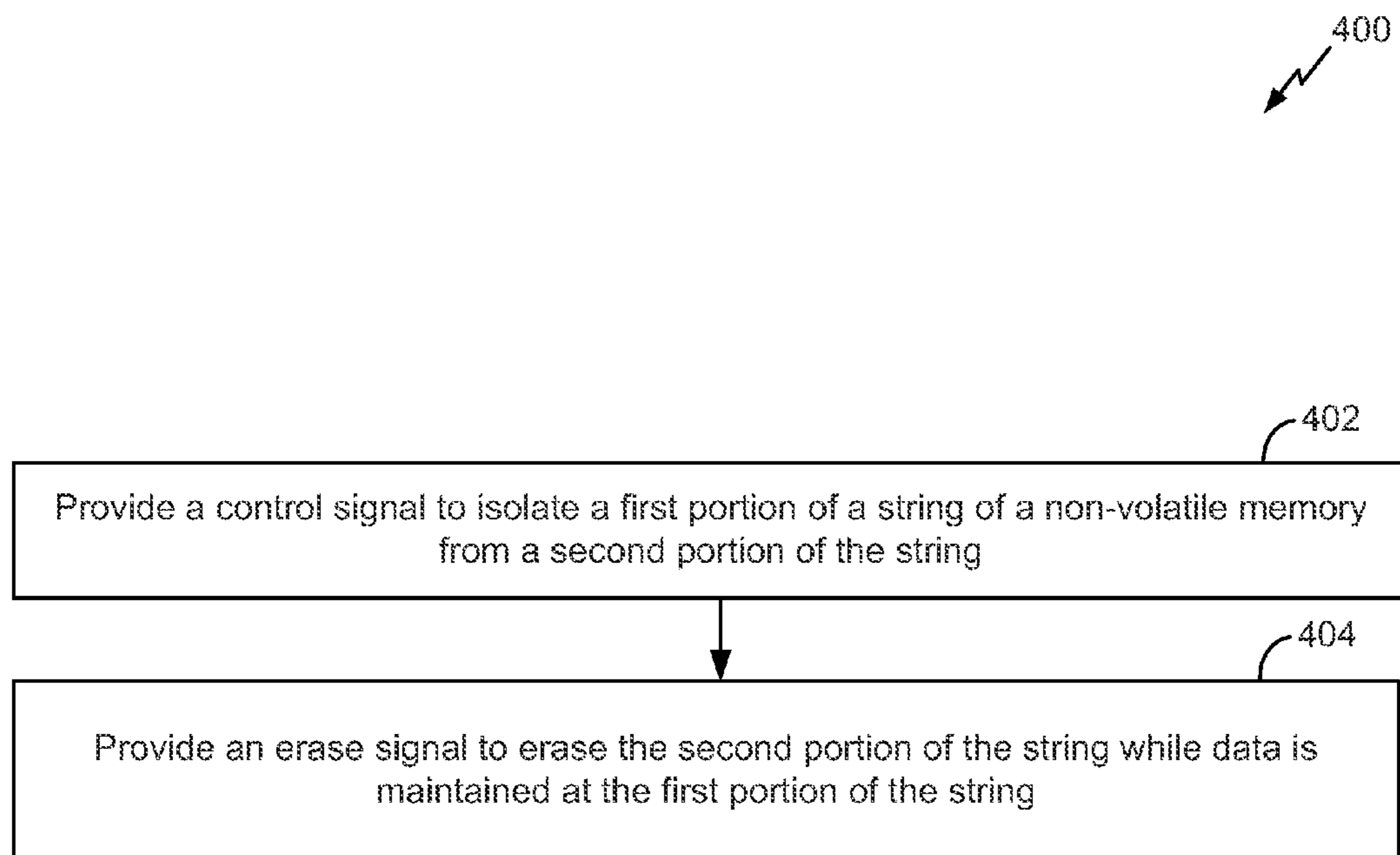


FIG. 4

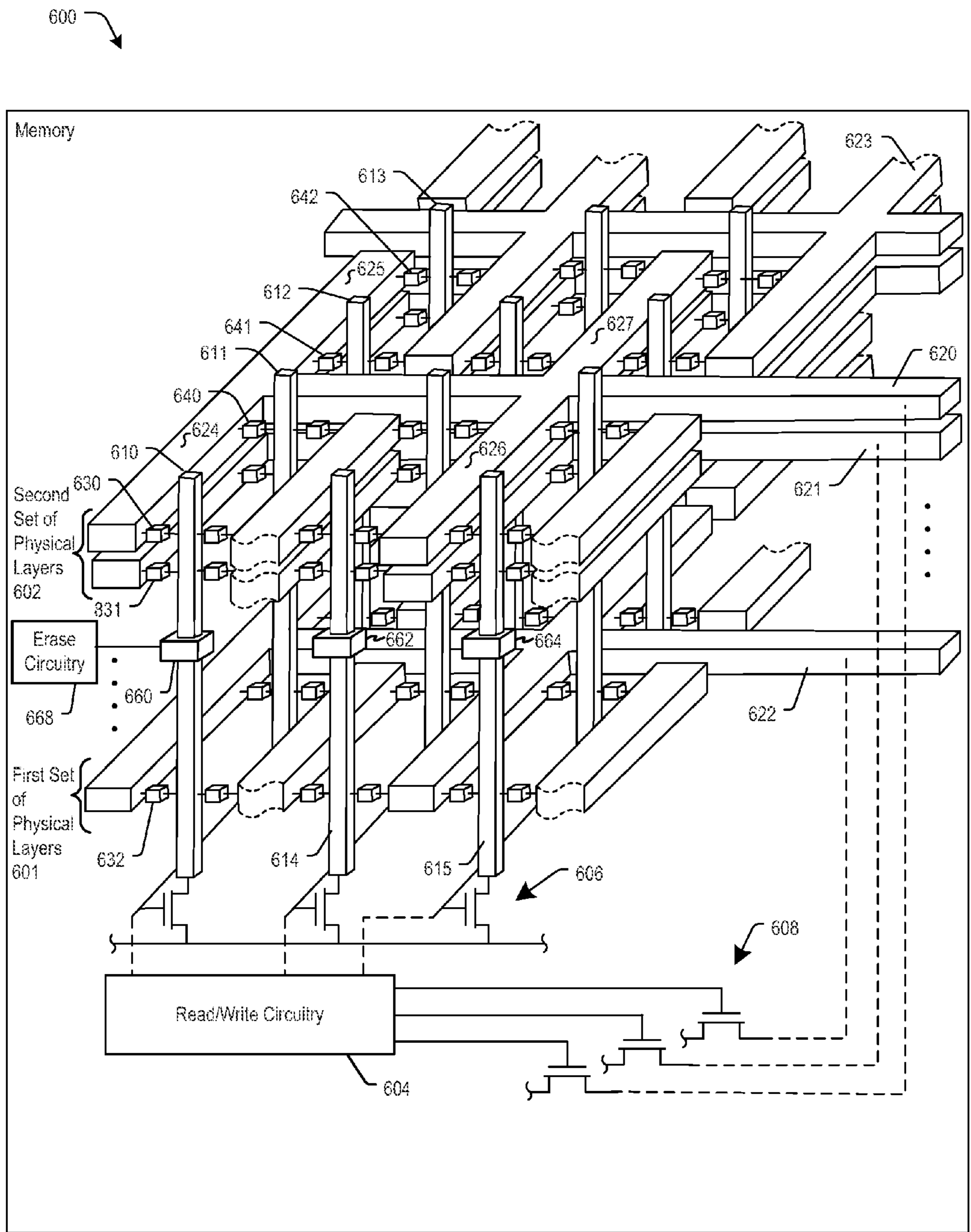


FIG. 6

1**PARTIAL BLOCK ERASE FOR A THREE
DIMENSIONAL (3D) MEMORY****CROSS-REFERENCE TO RELATED
APPLICATIONS**

The present application claims priority from U.S. application Ser. No. 14/304,419 filed Jun. 13, 2014, which is incorporated by reference herein in its entirety.

FIELD OF THE DISCLOSURE

The present disclosure is generally related to a partial block erase for a three dimensional (3D) memory.

BACKGROUND

Non-volatile data storage devices, such as embedded memory devices (e.g., embedded MultiMedia Card (eMMC) devices) and removable memory devices (e.g., removable universal serial bus (USB) flash memory devices and other removable storage cards), have allowed for increased portability of data and software applications. Users of non-volatile data storage devices increasingly rely on the non-volatile storage devices to store and provide rapid access to a large amount of data.

In non-volatile data storage devices having a three dimensional (3D) memory, erasing a block of the 3D memory may include time consuming and power expending processes. Additionally, when erasing the block, each wordline of the block is erased regardless of whether the wordline is already in an erased state and regardless of whether the wordline is approaching an end-of-life (e.g., failure) condition.

SUMMARY

Techniques are disclosed to perform a partial block erase for a three dimensional (3D) memory. For example, a data storage device may include a 3D memory having one or more blocks. Each block may include a plurality of sub-blocks that are erasable independently of the other sub-blocks of the block. For example, the block can include one or more switches to electrically isolate sub-blocks during an erase operation.

By performing an erase operation on a sub-block, rather than on an entire block, of the 3D memory, the erase operation may be performed more quickly and less power may be used. Additionally, by being able to perform erase operations on sub-blocks of the 3D memory, wordlines that have been identified as nearing an end-of-life condition may be selectively isolated from an erase operation that is performed on the rest of the block. By selectively isolating the wordlines that have been identified, a life of the wordlines may be extended.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a block diagram of a particular illustrative embodiment of a system including a data storage device that includes a memory device that is configurable to perform a partial block erase;

FIG. 2 illustrates an embodiment of the memory device of FIG. 1;

FIG. 3 illustrates another embodiment of the memory device of FIG. 1;

FIG. 4 is a flow diagram of an illustrative embodiment of a method to perform a partial block erase;

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FIG. 5 is a block diagram of a particular embodiment of the non-volatile memory of one the data storage device of FIG. 1; and

FIG. 6 is a block diagram of another particular embodiment of the non-volatile memory of the data storage device of FIG. 1.

DETAILED DESCRIPTION

Particular embodiments of the present disclosure are described with reference to the drawings. In the description, common features are designated by common reference numbers throughout the drawings.

FIG. 1 is a block diagram of a particular illustrative embodiment of a system **100** including a data storage device **102** and a host device **130**. The system **100** may be configured to enable the data storage device **102** to perform a partial block erase on a three dimensional (3D) memory.

The data storage device **102** may be embedded within the host device **130**, such as in accordance with an embedded MultiMedia Card (eMMC®) (trademark of Joint Electron Devices Engineering Council (JEDEC) Solid State Technology Association, Arlington, Va.) configuration. Alternatively, the data storage device **102** may be removable from (i.e., “removably” coupled to) the host device **130**. For example, the data storage device **102** may be removably coupled to the host device **130** in accordance with a removable universal serial bus (USB) configuration.

The data storage device **102** may be coupled to the host device **130** via a communication path **110**, such as a wired communication path and/or a wireless communication path. For example, the data storage device **102** may include an interface **108** (e.g., a host interface) that enables communication (via the communication path **110**) between the data storage device **102** and the host device **130**, such as when the interface **108** is coupled to the host device **130**.

The host device **130** may include a processor and a memory. The memory may be configured to store data and/or instructions that may be executable by the processor. The memory may be a single memory or may include one or more memories, such as one or more non-volatile memories, one or more volatile memories, or a combination thereof. The host device **130** may issue one or more commands to the data storage device **102**, such as one or more requests to read data from or write data to a memory **104** of the data storage device **102**. For example, the host device **130** may send data, such as user data **132** to be written to the memory **104** of the data storage device **102**.

The data storage device **102** includes a controller **120** coupled to the memory **104**, such as a non-volatile memory (e.g., a flash memory). The controller **120** may be coupled to the memory **104** via a bus **106**, an interface, another structure, or a combination thereof. The memory **104** has a three dimensional (3D) memory configuration, as described further herein. The memory **104** may store data, such as the user data **132**.

The memory **104** may be included on a memory die **103** that is separate from the controller **120** and coupled to the controller **120** (e.g., via the bus **106**). However, in other implementations, the memory **104** and the controller **120** may be included on a common die. The memory **104** may include multiple blocks that each includes a plurality of wordlines. The wordlines may be arranged in one or more layers. Each block may also include multiple “strings” of storage elements where the strings extend through the one or more layers, such as through each wordline. For example, the memory **104** may include a representative string **150**, such as a vertical string

(e.g., a NAND string). The string **150** may include a first portion **152** and a second portion **156**. The string **150** may also include (or be coupled to) a switch **154** that may be configurable to couple or decouple the first portion **152** and the second portion **156**. The switch **154** may be positioned (physically and/or electrically) between the first portion **152** and the second portion **156**, such as between a first storage element of the first portion **512** and a second storage element of the second portion **156**. For example, the switch **154** is configurable to selectively isolate the first portion **152** from the second portion **156**. In addition, while two portions **152**, **156** are shown in FIG. 1 and a single switch **154** is also shown, it should be understood that the string **150** may include more than two portions and more than one switch. Thus, the string **150** includes multiple portions that are selectively coupled or decoupled based on the switch **154**. In some embodiments, the switch **154** may include a transistor, such as a metal-oxide semiconductor (MOS) transistor.

The memory die **103** may further include read circuitry **140**, write circuitry **142**, and erase circuitry **144**. Although illustrated as separate components, the read circuitry **140**, the write circuitry **142**, the erase circuitry **144**, and/or a combination thereof, may be included in a single component of the memory die **103**. The read circuitry **140** and the write circuitry **142** may be configured to enable operations of reading data from the memory **104** and writing data to the memory **104**, respectively.

The erase circuitry **144** may be configured to enable erase operations to be performed on the memory **104**. For example, the erase circuitry **144** may be configured to enable block erase operations and/or partial block erase operations (e.g., sub-block erase operations), as described herein. To perform an erase operation, the erase circuitry **144** may send a control signal **134** and an erase signal **136** to the memory **104**. The control signal **134** may cause one or more switches included in the memory **104** to operate (e.g., open and/or close). For example, the control signal **134** may cause the switch **154** to be in a closed position and couple the first portion **152** of the string **150** to the second portion **156** of the string **150**. The erase signal **136** may cause one or more erase voltages to be applied to at least part of the memory **104** and to erase data stored in the memory **104**. The data that is erased responsive to the erase signal **136** may depend on a configuration of the switch **154** and on portion of the memory **104** to which the erase voltage is applied.

To illustrate, during a first type of erase operation (e.g., a partial block erase operation), the first portion **152** may be isolated from the second portion **156** by the switch **154** being in an open state based on the control signal **134**. With the first type of erase operation being performed, an erase voltage may be applied to the second portion **156** of the string **150** based on the erase signal **136**. When the erase voltage is applied to the second portion **156** and the switch **154** is in the open state, data corresponding to the second portion **156** may be erased while data is maintained at the first portion **152** of the string **150**. During a second type of erase operation, the first portion **152** may be coupled to the second portion **156** by the switch **154** being in a closed state. During a second erase operation corresponding to the second type of erase operation (e.g., a full block erase operation), the first portion **152** and the second portion **156** may be biased together at substantially the same voltage level. Although the first type of erase operation (e.g., the partial block erase operation) and the second type of erase operation (e.g., a full block erase operation) have been described with reference to a single string **150** of a block, it is understood that during each of the first type of erase

operation and the second type of erase operation, each string of the block may be configured as described with reference to the string **150**.

The memory **104** may also include one or more current sensors **146**. The current sensors **146** may be coupled to the memory **104**. For example, each current sensor (of the current sensors **146**) may be coupled to a different wordline of a portion of the memory **104** that is being erased. Each current sensor may determine an amount of current through a corresponding wordline when an erase operation is performed that is associated with the corresponding wordline. For example, during a particular erase operation to erase a particular wordline, a particular current sensor, such as one of the current sensors **146** that corresponds to the particular wordline may determine an amount of current through the particular wordline. Based on the particular amount of current, an indication of the amount of current, such as the current sensor data **126**, may be generated and provided to the controller **120**. The current sensor data **126** may enable the controller **120** to determine a health status of the particular wordline, as described further herein.

An illustrative example of the string **150** is illustrated and generally designated **180**. The example **180** depicts a cross-sectional elevation view of the string **150** having a vertical conductive channel structure extending through holes formed in a stack of wordlines to form a vertical column of storage elements. An example of a perspective view of a three dimensional (3D) memory is described with reference to FIGS. 5 and 6. The stack of wordlines may be associated with one or more physical layers (e.g., one or more physical levels).

The string **150** may be formed on a substrate **182**, such as a silicon (Si) substrate. The string **150** may include a plurality of storage elements. Each storage element (e.g., a memory cell) of the string **150** may include a bit cell, such as a representative bit cell **174**. The bit cell **174** may include (or be coupled to) a wordline, a portion of a charge trap, and a portion of a conductive channel. Each storage element (e.g., memory cell or bit cell) of the string **150** may be configured to store a data value, e.g., a bit value, such as "1" and "0," or a multi-bit value, such as in a two bit-per-cell (2-BPC) implementation, a three bit-per-cell (3-BPC) implementation, or another BPC implementation.

The string **150** may include the first portion **152** and the second portion **156**. The first portion **152** may be associated with and/or correspond to a first set of storage elements (e.g., one or more storage elements) and the second portion **156** may be associated with and/or correspond to a second set of storage elements (e.g., one or more storage elements). The first portion **152** (e.g., the first set of wordlines) may correspond to a first sub-block of a block of the memory **104** that includes the string **150**. The second portion **156** (e.g., the second set of wordlines) may correspond to a second sub-block of a block of the memory **104** that includes the string **150**. The first set of storage elements and the second set of storage elements include the same number of storage elements or a different number of storage elements. In some embodiments, the first set of storage elements may include a single storage element, as an illustrative, non-limiting example.

The string **150** may include a conductive channel **186** (e.g., a vertical channel). The conductive channel **186** may be coupled the plurality of storage elements, such as the first set of storage elements and to the second set of storage elements. Each storage element of the plurality of storage elements may correspond to a different wordline. The first set of storage elements maybe included in a first group of (one or more) physical layers (e.g., a first physical level) and may corre-

spond to a first set of wordlines including a representative first wordline **188**. A first charge trap layer **170** may be positioned between the first set of wordlines and the conductive channel **186** (e.g., forming a sheath around the conductive channel **186**). Although the first set of storage elements is illustrated as being above the substrate **182** with no intervening storage elements, another one or more other sets of storage elements may be between the substrate **182** and the first set of storage elements (e.g., another group of physical layers may be between the substrate **182** and the first group of physical layers).

The second group of storage elements may be included in a second group of (one or more) physical layers (e.g., a second physical level) and may correspond to a second set of wordlines including a representative second wordline **198**. A second charge trap layer **176** may be positioned between the second set of wordlines and the second conductive channel **196**. Although the first charge trap layer **170** and the second charge trap layer **176** are illustrated as separate layers, in other embodiments, the first charge trap layer **170** and the second charge trap layer **176** may be a single layer.

The switch **154** may be coupled to the string **150**. For example, the switch may be coupled to the conductive channel **186**. The switch **154** may be configurable to couple or decouple (e.g., electrically connect or electrically isolate) the first portion **152** of the string **150** to the second portion **156** of the string **150**. To illustrate, the switch **154** may couple or may decouple the first portion **152** and the second portion **156** based on the control signal **134**.

The string **150** (e.g., the conductive channel **186**) may be coupled to a plurality of terminals. For example, the plurality of terminals include a first bias terminal **162**, a second bias terminal **164**, a third bias terminal **166**, and a fourth bias terminal **168**. In the illustrated embodiment, the first bias terminal **162** is located at a first end of the first portion **152** and the second bias terminal **164** is located at a second end of the first portion **152**. The third bias terminal **166** is located at a first end of the second portion **156** and the fourth bias terminal **168** is located at a second end of the second portion **156**.

The plurality of terminals may be configured to enable an erase voltage to be applied to at least a part of the string **150** (e.g., at least part of the conductive channel **186**) based on an erase signal, such as the erase signal **136**. For example, when the first portion **152** is isolated from the second portion **156**, a first erase operation may be performed on the second portion **156** of the string **150** to erase data at the second portion **156** while data is maintained at the first portion **152** of the string **150**. To erase the data at the second portion **156**, an erase voltage may be applied to the second portion **156** of the string **150** (e.g., to the third bias terminal **166** and/or the fourth bias terminal **168**) and a particular voltage may be applied to each wordline of the second set of wordlines (e.g., the second sub-block). To illustrate, to erase the storage elements corresponding to the second portion **156** of the string **150**, the particular voltage (applied to the second set of wordlines) may be associated with a first potential and the erase voltage may be associated with a second potential that is opposite of the first potential. For example, the first potential may be a positive voltage and the second potential may be a negative voltage or zero volts (e.g., a ground potential). A difference in the first potential and the second potential may erase a storage element (e.g., drain a charge that is stored at a charge trap of a bit cell).

The controller **120** is coupled to the memory **104** and is configured to determine whether to enable the switch **154** to couple the first portion **152** and the second portion **156** or to disable the switch **154** to decouple the first portion **152** from

the second portion **156**. For example, the controller **120** may include hardware and/or software, such as a processor (not shown) to execute firmware to determine whether to enable or disable the switch **154**. The controller **120** may initiate different types of erase operations by sending a command **172** (e.g., an erase command) to the memory **104**. In a first type of an erase operation, the first portion **152** is decoupled from the second portion **156** while in other types of erase operations the first portion **152** is coupled to the second portion **156** (so data within both the first portion **152** and the second portion **156** may be erased). Thus, the controller **120** may selectively erase one or more particular portions of the string **150**.

The controller **120** may include a random access memory (RAM) **122**. The RAM **122**, such as a volatile memory, may be configured to store a tracking table **124**. The tracking table **124** may store current sensor data, such as the current sensor data **126**, received from the one or more current sensors **146**. The controller **120** may collect current data (e.g., such as the current sensor data **126** indicating an amount of current sensed through a particular wordline during an erase operation), corresponding to the particular wordline, for a period of time. The current data for the particular wordline over the period of time may enable the controller **120** to determine health data associated with the particular wordline. The health data may indicate if and when the particular wordline is nearing an end-of-life (e.g., a failure). For example, the controller **120** may determine that the particular wordline is nearing the end-of-life based on an increase in the amount of current (flowing through the wordline during erase operations) over time. If the particular wordline fails, the controller **120** may have to decommission (e.g., no longer use) a particular block that includes the particular wordline. When the controller **120** identifies the particular wordline as nearing the end-of-life, the controller **120** may send the command **172** to the memory **104** to configure the memory **104** (e.g., one or more switches) to isolate the particular wordline during erase operations performed on the particular block. By avoiding performing erase operations on the wordline (e.g., a sub-block of the particular block that includes the particular wordline), a life of the particular wordline may be extended and endurance (e.g., usability) of the particular block may be increased.

The controller **120** may be configured to receive data and commands (e.g., instructions) from the host device **130** and may access the memory **104** based on the received commands. The controller **120** may send one or more write requests (e.g., a write command **128**) to the memory **104** to store the data to a specified address of the memory **104**. The write request may specify a physical address of a portion of the memory **104** (e.g., a physical address of a word line of the memory **104**) that is to store the data. The controller **120** may be configured to send a read request to the memory **104** to access data from a specified address of the memory **104**. To illustrate, the controller **120** may send a read request (e.g., a read command **126**) to access the data stored in the memory **104**. The read request may specify the physical address of a portion of the memory **104** (e.g., a physical address of a word line storing the data).

During operation, the memory die **103** (e.g., the erase circuitry **144**) of the data storage device **102** may receive the command **172** from the controller **120**. The command **172** may instruct the erase circuitry **144** to configure a block of the memory **104** to erase the second sub-block (e.g., the second set of wordlines) corresponding to the second portion **156** of the string **150**.

Based on the command **172**, the erase circuitry **144** may send the control signal **134** to the memory **104** to cause the

switch **154** to decouple the first portion **152** and the second portion **156**. When the first portion **152** and the second portion **156** are decoupled, the erase circuitry **144** may send the erase signal **136** to the memory **104**. The erase signal **136** may cause an erase voltage to be applied the second portion **156** of the string **150**, such as to the second sub-block. Based on the erase voltage applied to the second portion **156**, data stored at the second set of storage elements corresponding to the second portion **156** (e.g., the second sub-block) may be erased, while data is maintained at the first set of storage elements corresponding to the first portion **152** (e.g., the first sub-block).

Although the tracking table **124** is illustrated as a single table, the tracking table **124** may include multiple tables. Additionally or alternatively, although the tracking table **124** is illustrated as being stored at the RAM **122** included in the controller **120**, in other implementations at least a portion of the tracking table **124** may be stored at the memory **104**, at a memory of the host device **130**, at another memory that is coupled to the controller **120**, or a combination thereof. Additionally or alternatively, the controller **120** may include a single memory component, such as the RAM **122**, or may include multiple distinct memory components and/or multiple different types of memory components.

Additionally, the data storage device **102** may include an error correction code (ECC) engine (not shown). The ECC engine may be configured to receive data, such as the data **132**, and to generate one or more error correction code (ECC) codewords (e.g., including a data portion and a parity portion) based on the data. For example, the ECC engine may include an encoder configured to encode the data using an ECC encoding technique. The ECC engine may include a Reed-Solomon encoder, a Bose-Chaudhuri-Hocquenghem (BCH) encoder, a low-density parity check (LDPC) encoder, a turbo encoder, an encoder configured to encode the data according to one or more other ECC techniques, or a combination thereof, as illustrative, non-limiting examples.

The ECC engine may include a decoder configured to decode data read from the memory **104** to detect and correct bit errors that may be present in the data. For example, the ECC engine may correct a number of bit errors up to an error correction capability of an ECC technique used by the ECC engine. A number of errors identified by the ECC engine may be tracked by the controller **120**, such as by the ECC engine. For example, based on the number of errors, the ECC engine may determine a bit error rate (BER) associated with one or more blocks of the memory **104** that may be used to determine when one or more portion of the memory **104** may be approaching an end-of-life condition.

By selectively isolating the first portion **152** and the second portion **156** using the switch **154**, a partial block erase operation (e.g., a sub-block erase operation) may be performed on a block of a 3D memory that includes the string **150**. The partial block erase operation may advantageously be performed more quickly and use less power than a full block erase operation. Additionally, by being able to perform the partial block erase operation, wordlines (of the block) that have been identified as nearing an end-of-life may be selectively isolated during erase operations to increase a life of the wordlines and a usefulness of blocks that include the wordlines.

Referring to FIG. **2**, a first example of a memory is illustrated and generally designated **200**. The memory may include or correspond to the memory **104** of FIG. **1**. The example **200** depicts a cross-sectional elevation view of the string **150**.

The string **150** may include a conductive channel **206**. The conductive channel **206** may include or correspond to the conductive channel **186** of FIG. **1**. It is noted that one or more charge trap layers of the string **150** are not illustrated for clarity of illustration. The conductive channel **206** may include the first portion **152**, the second portion **156**, and a third portion **258**. The first portion **152** may correspond to a first set of storage elements (e.g., one or more storage elements), the second portion **156** may correspond to a second set of storage elements (e.g., one or more storage elements), and the third portion **258** may correspond to a third set of storage elements (e.g., one or more storage elements). Although the string **150** is illustrated as including three portions, the string **150** may include more than three portions or fewer than three portions.

The string **150** may also include (or be coupled to) the switch **154** (e.g., a first switch) and a second switch **204**. The first switch **154** may be configurable to couple or decouple the first portion **152** and the second portion **156**. The second switch **204** may be configurable to couple or decouple the second portion **156** and the third portion **258**. For example, the first switch **154** and/or the second switch **204** may be selectively configured based on one or more control signals, such as the control signal **134** of FIG. **1**, received from the erase circuitry **144**.

The string **150** may be coupled to one or more terminals (e.g., one or more bias terminals). For example, the one or more terminals may include the first bias terminal **162**, the second bias terminal **164**, the third bias terminal **166**, the fourth bias terminal **168**, a fifth bias terminal **270**, and a sixth bias terminal **272**. To illustrate, the first bias terminal **162** may be located at a first end of the first portion **152** and the second bias terminal **164** may be located at a second end of the first portion **152**. The third bias terminal **166** may be located at a first end of the second portion **156** and the fourth bias terminal **168** may be located at a second end of the second portion **156**. The fifth bias terminal **270** may be located at a first end of the third portion **258** and the sixth bias terminal **272** may be located at a second end of the third portion **258**.

The first switch **154** and/or the second switch **204** may be selectively activated and/or deactivated to configure the string **150** for one or more erase operations. For example, the first switch **154** and the second switch **204** may couple and decouple one or more portions of the string **150** to configure the string **150** for a block erase operation or for sub-block erase operations.

To illustrate, prior to and during a first erase operation (corresponding to a first erase signal), the first switch **154** may be configured to decouple the first portion **152** and the second portion **156** and the second switch **204** may be configured to decouple the second portion **156** and the third portion **258**. Accordingly, each portion of the string **150** may be isolated from the other portions of the string **150**. The first erase operation may then be performed to erase a single sub-block, such as a single sub-block corresponding to the first portion **152**, a single sub-block corresponding to the second portion **156**, or a single sub-block corresponding to the third portion **258**. To erase the sub-block corresponding to the first portion **152**, a bias voltage (e.g., an erase voltage) may be applied to first bias terminal **162** and/or to the second bias terminal **164**, but not to the third, fourth, fifth and sixth bias terminals **166-168, 270-272**. To erase the sub-block corresponding to the second portion **156**, a bias voltage (e.g., an erase voltage) may be applied to third bias terminal **166** and/or to the fourth bias terminal **168**, but not to the first, second, fifth and sixth bias terminals **162-164, 270-272**. To erase the sub-block corresponding to the third portion **258**, a bias voltage (e.g., an

erase voltage) may be applied to fifth bias terminal **270** and/or to the sixth bias terminal **272**, but not to the first, second, third, and fourth bias terminals **162-168**. It is also noted that a bias voltage (e.g., an erase voltage) may be concurrently applied to the first portion **152** and the third portion **258**, but not applied to the second portion **156**.

Prior to and during a second erase operation (corresponding to a second erase signal), the first switch **154** may be configured to couple the first portion **152** and the second portion **156** and the second switch **204** may be configured to couple the second portion **156** and the third portion **258**. Accordingly, each portion of the string **150** may be coupled together. The second erase operation may then be performed to erase a block, such as a block corresponding to the string **150** (including each of the sub-blocks corresponding to the first portion **152**, the second portion **156**, and the third portion **258**). To erase the block corresponding to the string **150**, a bias voltage (e.g., an erase voltage) may be applied to one or more of the bias terminals **162-168**, **270-272**.

Prior to and during a third erase operation (corresponding to a third erase signal), the second switch **204** may be configured to couple the second portion **156** and the third portion **258**. Additionally, prior to and during the third erase operation, the first switch **154** may be configured to decouple the first portion **152** and the second portion **156**. The third erase operation may then be performed to erase multiple sub-blocks that include a sub-block corresponding to the second portion **156** and a sub-block corresponding to the third portion **258**. To erase the multiple sub-blocks, a bias voltage (e.g., an erase voltage) may be applied to one or more of the third bias terminal **166**, the fourth bias terminal **168**, the fifth bias terminal **270**, and the sixth bias terminal **272**. It is also noted that when the second switch **204** is configured to couple the second portion **156** and the third portion **258** and the first switch is configured to decouple the first portion **152** and the second portion **156**, an erase operation may be performed to erase a single sub-block corresponding to the first portion **152** without erasing data corresponding to the sub-blocks that correspond to the second portion **156** and the third portion **258**.

Prior to and during a fourth erase operation (corresponding to a fourth erase signal), the second switch **204** may be configured to decouple the second portion **156** and the third portion **258**. Additionally, prior to and during the fourth erase operation, the first switch **154** may be configured to couple the first portion **152** and the second portion **156**. The fourth erase operation may then be performed to erase multiple sub-blocks that include a sub-block corresponding to the first portion **152** and a sub-block corresponding to the second portion **156**. To erase the multiple sub-blocks, a bias voltage (e.g., an erase voltage) may be applied to one or more of the first bias terminal **162**, the second bias terminal **164**, third bias terminal **166**, and the fourth bias terminal **168**. It is also noted that when the second switch **204** is configured to decouple the second portion **156** and the third portion **258** and the first switch is configured to couple the first portion **152** and the second portion **156**, an erase operation may be performed to erase a single sub-block corresponding to the third portion **258** without erasing data corresponding to the sub-blocks that correspond to the first portion **152** and the second portion **156**.

By selectively configuring the first switch **154** and/or the second switch **204**, an erase operation may be performed on less than an entire block (e.g., on one or more sub-blocks). By performing an erase operation on a sub-block of the 3D memory, rather than on an entire block, the erase operation may be performed more quickly and less power may be used.

Referring to FIG. 3, a second example of a memory is illustrated and generally designated **300**. The memory may include or correspond to the memory **104** of FIG. 1. The example **300** depicts a cross-sectional elevation view of the string **150**.

The string **150** may include multiple sets of storage elements. For example, the string **150** may include a first set of storage elements **352**, a second set of storage elements **356**, and a third set of storage elements **358**. The first set of storage elements **352** may correspond to a first portion of string **150**, such as the first portion **152** of FIG. 1. The second set of storage elements **356** may correspond to a second portion of string **150**, such as the second portion **156** of FIG. 1. The third set of storage elements **358** may correspond to a third portion of string **150**, such as the third portion **258** of FIG. 2. Each set of storage elements **352**, **356**, **358** may be coupled to a conductive channel of the string **150**, such as the conductive channel **186** of FIG. 1. Although FIG. 3 illustrates three sets of storage elements **352**, **356**, **358**, the multiple sets of storage elements may include two sets of storage elements or more than three sets of storage elements.

The string **150** may be included in a block of the memory. Each of the multiple sets of storage elements **352**, **356**, **358** may correspond to a different sub-block of the block of the memory. Each of the sub-blocks may be erased independent of the other sub-blocks included in the block. Additionally, multiple sub-blocks may be erased during the same erase operation. For example, all of the sub-blocks or less than all of the sub-blocks may be erased during a single erase operation.

Each set of storage elements **352**, **356**, **358** may include multiple storage elements that are each coupled to a corresponding wordline. For example, a representative storage element **388** may be coupled to a wordline **336**. To illustrate, the storage element **388** may include or correspond to the bit cell **174** of FIG. 1. Each wordline may be coupled to a corresponding current sensor. For example, each wordline may be coupled to a different current sensor. To illustrate, the wordline **336** may be coupled to a current sensor **346**. Each current sensor may be configured to generate current sensor data, such as the current sensor data **126** of FIG. 1, during an erase operation performed on a corresponding wordline. The current sensor data may be provided to a controller, such as the controller **120** of FIG. 1, and/or a memory, such as the memory **104** or the RAM **122** of FIG. 1.

The multiple sets of storage elements **352**, **356**, **358** may be selectively coupled together by one or more switches, such as a first switch **396** and a second switch **398**. The first switch **396** may include or correspond to the switch **154** of FIG. 1. The second switch **398** may include or correspond to the second switch **204** of FIG. 2. The first switch **396** and/or the second switch **398** may be configured to selectively couple one or more sets of storage element based on one or more control signals, such as the control signal **134** of FIG. 1.

The multiple sets of storage elements **352**, **356**, **358** may be coupled to a bit line **304** and to a source line **306**. For example, the multiple sets of storage elements **352**, **356**, **358** may be coupled to the bit line **304** through a first select gate **322** (e.g., a first driver), and the multiple sets of storage elements **352**, **356**, **358** may be coupled to the source line **306** through a second select gate **324** (e.g., a second driver). To illustrate, the first select gate **322** may be between the bit line **304** and the first set of storage elements **352**. The second select gate **324** may be between the third set of storage elements **358** and the source line **306**.

One or more terminals **362-372** may be coupled to the string **150**. The one or more terminals may include a first terminal **362**, a second terminal **364**, a third terminal **366**, a

fourth terminal **368**, a fifth terminal **370**, and a sixth terminal **372**. The first terminal **362** may include or correspond to the first bias terminal **162** of FIG. **1**, the second terminal **364** may include or correspond to the second bias terminal **164** of FIG. **1**, the third terminal **366** may include or correspond to the third bias terminal **166** of FIG. **1**, the fourth terminal **368** may include or correspond to the fourth bias terminal **168** of FIG. **1**, the fifth terminal **370** may include or correspond to the fifth bias terminal **270** of FIG. **2**, and the sixth terminal **372** may include or correspond to the sixth bias terminal **272** of FIG. **2**. Although the string **150** is illustrated as being coupled to six terminals, the string **150** may be coupled to more than six terminals or fewer than six terminals.

Each of the terminals **362-372** may be coupled to erase circuitry **344**. The erase circuitry **344** may include or correspond to the erase circuitry **144** of FIG. **1**. The erase circuitry **344** may be configured to send one or more erase signals, such as the erase signal **136** of FIG. **1**, to one or more of the terminals **362-372**. The one or more erase signals may be used to apply a voltage (e.g., an erase voltage) to one or more terminals during an erase operation. Based on the configuration of the switches **396, 398**, the erase voltage may be selectively applied to one or more portions of the string **150**. For example, when the switches **396, 398** are in a first configuration (e.g., the first switch **396** is open and the first set of storage elements **352** is decoupled from the second set of storage elements **356**, a first erase signal may be applied to the first terminal **362** and/or to the second terminal **364** to erase the first set of storage elements **352**.

Referring to FIG. **4**, an illustrative embodiment of a method **400** to enable a partial block erase of a three dimensional (3D) memory is shown. For example, the method **400** may be performed by at a data storage device, such as the data storage device **102** (e.g., the erase circuitry **144**) of FIG. **1**.

The method **400** includes providing a control signal to isolate a first portion of a string of a non-volatile memory from a second portion of the string, at **402**. The non-volatile memory may be a 3D memory, such as the memory **104** of FIG. **1**. The non-volatile memory may include at least one block that includes the string, such as the string **150**. The string may include a first portion and a second portion. The first portion of the string may correspond to a first sub-block of the block and the second portion of the string may correspond to a second sub-block of the block. The control signal, such as the control signal **134** of FIG. **1**, may be provided to a switch that is configurable to couple or decouple the first portion of the string to the second portion of the string. For example, the switch may include or correspond to the switch **154** of FIG. **1**.

The method **400** further includes providing an erase signal to erase the second portion of the string while data is maintained at the first portion of the string, at **404**. For example, the erase signal may include or correspond to the erase signal **136** of FIG. **1**.

In some embodiments, providing the first erase signal may include applying a first voltage level on one or more wordlines corresponding to the second portion of the string. Alternatively or additionally, providing the first erase signal may include applying a second voltage level on a portion of a conductive channel of the string. The portion of the conductive channel corresponds to the second portion of the string. The first voltage level may be associated with a first voltage potential and the second voltage level may be associated with a second voltage potential, such that the first voltage potential and the second voltage potential are opposite potentials. To illustrate, the first voltage potential may be a positive voltage

potential and the second voltage potential may be a negative voltage potential or a ground potential.

The method **400** may enable a partial block erase of the non-volatile memory (e.g., a 3D memory) by isolating the first portion of each of the strings in a block from the second portion of each of the strings. Accordingly, during an erase operation corresponding to the erase signal, first data may be maintained at the first portion of the string while second data may be erased from the second portion of the string.

The method **400** of FIG. **4** may be initiated or controlled by an application-specific integrated circuit (ASIC), a processing unit, such as a central processing unit (CPU), a digital signal processor (DSP), a controller, another hardware device, a firmware device, a field-programmable gate array (FPGA) device, or any combination thereof. As an example, the method **400** of FIG. **4** can be initiated or controlled by one or more processors, such as one or more processors included in or coupled to a controller. A controller configured to perform the method **400** of FIG. **4** may be able to perform a partial block erase (e.g., a sub-block erase) of a 3D memory.

FIG. **5** illustrates an embodiment of a 3D memory **500** in a NAND flash configuration. The 3D memory **500** may correspond to the memory **104** of FIG. **1**. The 3D memory **500** includes multiple physical layers, such as a first set of one or more physical layers **501** (e.g., a first set of physical levels) and a second set of one or more physical layers **503** (e.g., a second set of physical levels), that are monolithically formed above a substrate **504**, such as a silicon substrate. Storage elements (e.g., memory cells), such as a representative memory cell **510**, are arranged in arrays in the physical layers.

A representative string **590** may include the representative memory cell **510** and a conductive channel **512**. The string **590** may include or correspond to the string **150** of FIG. **1**. The representative memory cell **510** includes a charge trap structure **514** between a wordline/control gate (WL4) **528** and the conductive channel **512**. The charge trap may include or correspond to the first charge trap layer **170** or the second charge trap layer **176** of FIG. **1**. Charge may be injected into or drained from the charge trap structure **514** via biasing of the conductive channel **512** relative to the wordline **528**. For example, the charge trap structure **514** may include silicon nitride and may be separated from the wordline **528** and the conductive channel **512** by a gate dielectric, such as a silicon oxide. An amount of charge in the charge trap structure **514** affects an amount of current through the conductive channel **512** during a read operation of the memory cell **510** and indicates one or more bit values that are stored in the memory cell **510**. The conductive channel **512** may include or correspond to the conductive channel **186** of FIG. **1**.

The 3D memory **500** includes multiple erase blocks, including a first block (block **0**) **550**, a second block (block **1**) **552**, and a third block (block **2**) **554**. Each block **550-554** includes a “vertical slice” of the physical layers **502** that includes a stack of wordlines, illustrated as a first wordline (WL0) **520**, a second wordline (WL1) **522**, a third wordline (WL2) **524**, a fourth wordline (WL3) **526**, a fifth wordline (WL4) **528**, a sixth wordline (WL5) **570**, a seventh wordline (WL6) **572**, an eighth wordline (WL7) **574**, a ninth wordline (WL8) **576**, and a tenth wordline (WL9) **578**. Multiple conductive channels (having a substantially vertical orientation with respect to FIG. **5**) extend through the stack of wordlines. Each conductive channel may be associated with a different string, such as a NAND string. Each conductive channel is coupled to a storage element in each wordline **520-528, 570-578**, forming a NAND string of storage elements. FIG. **5** illustrates three blocks **550-554**, ten wordlines **520-528, 570-578** in each block, and three conductive channels in each

block for clarity of illustration. However, the 3D memory **500** may have more than three blocks, more than ten wordlines per block, and more than three conductive channels per block.

Read/write circuitry **560** is coupled to the conductive channels via multiple conductive lines, illustrated as a first bit line (BL0) **530**, a second bit line (BL1) **532**, and a third bit line (BL2) **534** at a “top” end of the conductive channels (e.g., farther from the substrate **504**) and a first source line (SL0) **540**, a second source line (SL1) **542**, and a third source line (SL2) **544** at a “bottom” end of the conductive channels (e.g., nearer to or within the substrate **504**). The read/write circuitry **560** is illustrated as coupled to the bit lines **530-534** via “P” control lines, coupled to the source lines **540-544** via “M” control lines, and coupled to the wordlines **520-528** via “N” control lines. Each of P, M, and N may have a positive integer value based on the specific configuration of the 3D memory **500**. In the illustrative example of FIGS. 5, P=3, M=3, and N=10.

In a particular embodiment, each of the bit lines and each of the source lines may be coupled to the same end (e.g., the top end or the bottom end) of different conductive channels. For example, a particular bit line may be coupled to the top of a conductive channel **592** and a particular source line may be coupled to the top of the conductive channel **512**. The bottom of the conductive channel **592** may be coupled (e.g., electrically coupled) to the bottom of the conductive channel **512**. Accordingly, the conductive channel **592** and the conductive channel **512** may be coupled in series and may be coupled to the particular bit line and the particular source line.

Each of the conductive channels (e.g., each string) may be coupled to one or more corresponding switches, such as representative switches **580-584**. The representative switch **584** may be configurable to couple and/or decouple a first portion of the string **590** (corresponding to the first set of physical layers **502**) and a second portion of the string **590** (corresponding to the second set of physical layers **503**). The switch **584** may include or correspond to the switch **154** of FIG. 1, the switch **204** of FIG. 2, and/or the switches **396, 398** of FIG. 3. Each of the switches may be coupled to erase circuitry **586**. As illustrated in FIG. 5, only the switch **584** is depicted as being coupled to the erase circuitry **586** for clarity of illustration. The erase circuitry **586** may operate as described with respect to the erase circuitry **144** of FIG. 1 and/or the erase circuitry **344** of FIG. 3. FIG. 5 does not illustrate terminals (e.g., bias terminals) coupled to each of the conductive channels for clarity of illustration. It is understood that the 3D memory **500** may include one or more terminals coupled to each of the conductive channels, as described with reference to the terminals **162-186** of FIG. 1, the terminals **270-272** of FIG. 2, and/or the terminals **362-372** of FIG. 3.

The read/write circuitry **560** may operate as described with respect to the read circuitry **140** and/or the write circuitry **142** of FIG. 1. For example, data may be stored to storage elements coupled to the wordline **528** and the read/write circuitry **560** may read bit values from the storage elements. As another example, the read/write circuitry **560** may apply selection signals to control lines coupled to the wordlines **520-528**, the bit lines **530-534**, and the source lines **540-542** to cause a programming voltage (e.g., a voltage pulse or series of voltage pulses) to be applied across selected storage element(s) of the selected wordline (e.g., the fourth wordline **528**).

During a read operation, the controller **120** may receive a request from a host device, such as the host device **130** of FIG. 1. The controller **120** may cause the read/write circuitry **560** to read bits from particular storage elements of the 3D memory **500** by applying appropriate signals to the control

lines to cause storage elements of a selected wordline to be sensed. Accordingly, the 3D memory **500** having multiple conductive channels in a stacked configuration may be configured to read from and write data to one or more storage elements.

During an erase operation, such as a partial block erase operation, a block of the memory **500** to be erased may be identified. For example, the first block (block **0**) **550** may be identified to have a first portion (e.g., a sub-block) of the first block (block **0**) **550** erased. The first portion of the first block (block **0**) **550** may correspond to the wordlines **520-528** that are associated with the first set of physical layers **502**. The erase circuitry **586** may send one or more control signals to disable the switches **580-584**. Accordingly, the first portion of the first block (block **0**) **550** (e.g., a first portion of each of the strings included in the first block (block **0**) **550**) may be isolated from a second portion (e.g., a second sub-block) of the first block (block **0**) **550** that corresponds to the second set of physical layers **503**. An erase voltage may be applied to the first portion of the first block (block **0**) **550** to erase the first sub-block. For example, the erase voltage may be applied to a first portion of each of the strings included in the first block (block **0**) **550**.

FIG. 6 is a diagram of a particular embodiment of a memory **600**. The memory **600** may be included in the data storage device **102** of FIG. 1. FIG. 6 illustrates a portion of a three dimensional architecture of the memory **600**, such as the memory **104**. In the embodiment illustrated in FIG. 6, the memory **600** is a vertical bit line Resistive Random Access Memory (ReRAM) with a plurality of conductive lines in physical layers over a substrate (e.g., substantially parallel to a surface of the substrate), such as representative wordlines **620, 621, 622, and 623** (only a portion of which is shown in FIG. 6) and a plurality of vertical conductive lines through the physical layers, such as representative bit lines **610, 611, 612, and 613**. The wordline **622** may include or correspond to a first set of one or more physical layers **601** and the wordlines **620, 621** may include or correspond to a second set of one or more of physical layers **602**.

The memory **600** also includes a plurality of resistance-based storage elements (e.g., memory cells), such as representative storage elements **630, 631, 632, 640, 641, and 642**, each of which is coupled to a bit line and a wordline in arrays of memory cells in multiple physical layers over the substrate (e.g., a silicon substrate). The memory **600** also includes read/write circuitry **604**, such as the read circuitry **140** and/or the write circuitry **142** of FIG. 1. The read/write circuitry **604** is coupled to wordline drivers **608** and bit line drivers **606**.

In the embodiment illustrated in FIG. 6, each of the wordlines includes a plurality of fingers (e.g., a first wordline **620** includes fingers **624, 625, 626, and 627**). Each finger may be coupled to more than one bit line. To illustrate, a first finger **624** of the first wordline **620** is coupled to a first bit line **610** via a first storage element **630** at a first end of the first finger **624** and is coupled to a second bit line **611** via a second storage element **640** at a second end of the first finger **624**.

In the embodiment illustrated in FIG. 6, each bit line may be coupled to more than one wordline. To illustrate, the first bit line **610** is coupled to the first wordline **620** via the first storage element **630** and is coupled to a third wordline **622** via a third storage element **632**.

In the embodiment illustrated in FIG. 6, each bit line, such as the representative bit lines **610, 611, 612, and 613**, may be coupled to one or more corresponding switches, such as representative switches **660-664**. The representative switch **660** may be configurable to couple and/or decouple a first portion of the bit line **610** (corresponding to the first set of physical

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layers 601) and a second portion of the bit line 610 (corresponding to the second set of physical layers 602). The switch 660 may include or correspond to the switch 154 of FIG. 1, the switch 204 of FIG. 2, the switches 396, 398 of FIG. 3, and/or the switches 580-584 of FIG. 5. Each of the switches may be coupled to erase circuitry 668. As illustrated in FIG. 6, only the switch 660 is depicted as being coupled to the erase circuitry 668 for clarity of illustration. The erase circuitry 668 may operate as described with respect to the erase circuitry 144 of FIG. 1, the erase circuitry 344 of FIG. 3, and/or the erase circuitry 586 of FIG. 5. FIG. 6 does not illustrate terminals (e.g., bias terminals) coupled to each of the bit lines for clarity of illustration. It is understood that the memory 600 may include one or more terminals coupled to each of the conductive channels, as described with reference to the terminals 162-186 of FIG. 1, the terminals 270-272 of FIG. 2, and/or the terminals 362-372 of FIG. 3.

During a write operation, the controller 120 may receive data from a host device, such as the host device 130 of FIG. 1. The controller 120 may send the data (or a representation of the data) to the memory 600. For example, the controller 120 may encode the data prior to sending the encoded data to the memory 600.

The read/write circuitry 604 may write the data to storage elements corresponding to the destination of the data. For example, the read/write circuitry 604 may apply selection signals to selection control lines coupled to the wordline drivers 608 and the bit line drivers 606 to cause a write voltage to be applied across a selected storage element. For example, to select the first storage element 630, the read/write circuitry 604 may activate the wordline drivers 608 and the bit line drivers 606 to drive a programming current (also referred to as a write current) through the first storage element 630. To illustrate, a first write current may be used to write a first logical value (e.g., a value corresponding to a high-resistance state) to the first storage element 630, and a second write current may be used to write a second logical value (e.g., a value corresponding to a low-resistance state) to the first storage element 630. The programming current may be applied by generating a programming voltage across the first storage element 630 by applying a first voltage to the first bit line 610 and to wordlines other than the first wordline 620 and applying a second voltage to the first wordline 620. In a particular embodiment, the first voltage is applied to other bit lines (e.g., the bit lines 614, 615) to reduce leakage current in the memory 600.

During a read operation, the controller 120 may receive a request from a host device, such as the host device 130 of FIG. 1. The controller 120 may cause the read/write circuitry 604 to read bits from particular storage elements of the memory 600 by applying selection signals to selection control lines coupled to the wordline drivers 608 and the bit line drivers 606 to cause a read voltage to be applied across a selected storage element. For example, to select the first storage element 630, the read/write circuitry 604 may activate the wordline drivers 608 and the bit line drivers 606 to apply a first voltage (e.g., 0.7 volts (V)) to the first bit line 610 and to wordlines other than the first wordline 620. A lower voltage (e.g., 0 V) may be applied to the first wordline 620. Thus, a read voltage is applied across the first storage element 630, and a read current corresponding to the read voltage may be detected at a sense amplifier of the read/write circuitry 604. The read current corresponds (via Ohm's law) to a resistance state of the first storage element 630, which corresponds to a logical value stored at the first storage element 630. The logical value read from the first storage element 630 and other elements read during the read operation may be provided to

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the controller 120. Accordingly, each of the bit lines 610, 611, 612, and 613 may include multiple portions and the multiple portions of a particular bit line may be in a stacked configuration.

Although various components of the data storage device 102 and the host device 130 depicted herein are illustrated as block components and described in general terms, such components may include one or more microprocessors, state machines, or other circuits configured to enable the controller 120 and/or the memory (e.g., the read circuitry 140, the write circuitry 142, and/or the erase circuitry 144) of FIG. 1 to perform operations described herein. One or more aspects of the controller 120 and/or the memory 104 (e.g., the read circuitry 140, the write circuitry 142, and/or the erase circuitry 144) of FIG. 1 may be implemented using a microprocessor or microcontroller programmed to perform operations described herein, such as one or more operations of method 400 of FIG. 4. In a particular embodiment, the controller 120 and/or the memory (e.g., the read circuitry 140, the write circuitry 142, and/or the erase circuitry 144) of FIG. 1 includes a processor executing instructions that are stored at a memory, such as a non-volatile memory of the data storage device 102 or the host device 130. Alternatively or additionally, executable instructions that are executed by the processor may be stored at a separate memory location that is not part of the non-volatile memory, such as at a read-only memory (ROM) of the data storage device 102 or the host device 130.

In an illustrative example, the processor may execute the instructions to provide a control signal to isolate a first portion of a string of a memory from a second portion of the string. The instructions to provide the control signal may include instructions to receive a command (e.g., an erase command) from a controller, instructions to identify one or more switches included in a memory (e.g., a 3D memory) to be enabled, instructions to identify one or more switches included in the memory to be disabled, instructions to identify a block of the memory to be erased, instructions to determine whether to initiate a full block erase operation or a partial block erase operation, and/or instructions to identify one or more sub-blocks to be erased, as illustrative, non-limiting examples. The processor may execute instructions to provide an erase signal to erase the second portion of the string while data is maintained at the first portion of the string. The instructions to provide the erase signal may include instructions to send the erase signal to the memory, instructions to identify one or more terminals to receive an erase voltage, instructions to identify one or more wordlines to be erased, and/or instructions to determine a current value for each wordline erased during an erase operation corresponding to the erase signal, as illustrative, non-limiting examples.

The data storage device 102 may be attached to or embedded within one or more host devices, such as within a housing of a host communication device, which may correspond to the host device 130. The data storage device 102 may be within a packaged apparatus such as a wireless telephone, a personal digital assistant (PDA), a gaming device or console, a portable navigation device, a computer device (e.g., a tablet or a laptop), or other device that uses internal non-volatile memory. However, in other embodiments, the data storage device 102 may be a portable device configured to be selectively coupled to one or more external devices, such as the host device 130. For example, the data storage device 102 may be a removable device such as a Universal Serial Bus (USB) flash drive or a removable memory card, as illustrative examples.

The host device **130** may correspond to a mobile telephone, a music player, a video player, a gaming device or console, an electronic book reader, a personal digital assistant (PDA), a computer, such as a laptop, a tablet, or a notebook computer, a portable navigation device, another electronic device, or a combination thereof. The host device **130** may operate in compliance with a JEDEC Solid State Technology Association industry specification, such as an embedded MultiMedia Card (eMMC) specification or a Universal Flash Storage (UFS) Host Controller Interface specification. The host device **130** may operate in compliance with one or more other specifications, such as a Secure Digital (SD) Host Controller specification, as an illustrative example. Alternatively, the host device **130** may communicate with the data storage device **102** in accordance with another communication protocol.

The data storage device **102** may be configured to be coupled to the host device **130** as embedded memory, such as in connection with an embedded MultiMedia Card (eMMC®) (trademark of JEDEC Solid State Technology Association, Arlington, Va.) configuration, as an illustrative example. The data storage device **102** may correspond to an eMMC device. As another example, the data storage device **102** may correspond to a memory card, such as a Secure Digital (SD®) card, a microSD® card, a miniSD™ card (trademarks of SD-3C LLC, Wilmington, Del.), a MultiMediaCard™ (MMC™) card (trademark of JEDEC Solid State Technology Association, Arlington, Va.), or a CompactFlash® (CF) card (trademark of SanDisk Corporation, Milpitas, Calif.). The data storage device **102** may operate in compliance with a JEDEC industry specification. For example, the data storage device **102** may operate in compliance with a JEDEC eMMC specification, a JEDEC Universal Flash Storage (UFS) specification, one or more other specifications, or a combination thereof.

Semiconductor memory devices, such as the memory **104** and/or the RAM **122** include volatile memory devices, such as dynamic random access memory (“DRAM”) or static random access memory (“SRAM”) devices, non-volatile memory devices, such as resistive random access memory (“ReRAM”), electrically erasable programmable read only memory (“EEPROM”), flash memory (which can also be considered a subset of EEPROM), ferroelectric random access memory (“FRAM”), and other semiconductor elements capable of storing information. Each type of memory device may have different configurations. For example, flash memory devices may be configured in a NAND or a NOR configuration.

The memory devices can be formed from passive and/or active elements, in any combinations. By way of non-limiting example, passive semiconductor memory elements include ReRAM device elements, which in some embodiments include a resistivity switching storage element, such as an anti-fuse, phase change material, etc., and optionally a steering element, such as a diode, etc. Further by way of non-limiting example, active semiconductor memory elements include EEPROM and flash memory device elements, which in some embodiments include elements containing a charge storage region, such as a floating gate, conductive nanoparticles or a charge storage dielectric material.

Multiple memory elements may be configured so that they are connected in series or so that each element is individually accessible. By way of non-limiting example, flash memory devices in a NAND configuration (NAND memory) typically contain memory elements connected in series. A NAND memory array may be configured so that the array is composed of multiple strings of memory in which a string is

composed of multiple memory elements sharing a single bit line and accessed as a group. Alternatively, memory elements may be configured so that each element is individually accessible, e.g., in a NOR memory array. NAND and NOR memory configurations described have been presented as examples, and memory elements may be otherwise configured.

The semiconductor memory elements located within and/or over a substrate may be arranged in two or three dimensions, such as a two dimensional memory structure or a three dimensional memory structure.

In a two dimensional memory structure, the semiconductor memory elements are arranged in a single plane or a single memory device level. Typically, in a two dimensional memory structure, memory elements are arranged in a plane (e.g., in an x-z direction plane) which extends substantially parallel to a major surface of a substrate that supports the memory elements. The substrate may be a wafer over or in which the layer of the memory elements are formed or it may be a carrier substrate which is attached to the memory elements after they are formed. As a non-limiting example, the substrate may include a semiconductor material, such as silicon.

The memory elements may be arranged in the single memory device level in an ordered array, such as in a plurality of rows and/or columns. However, the memory elements may be arranged in non-regular or non-orthogonal configurations. The memory elements may each have two or more electrodes or contact lines, such as bit lines and wordlines.

A three dimensional memory array is arranged so that memory elements occupy multiple planes or multiple memory device levels, thereby forming a structure in three dimensions (i.e., in the x, y and z directions, where the y direction is substantially perpendicular and the x and z directions are substantially parallel to the major surface of the substrate).

As a non-limiting example, a three dimensional memory structure may be vertically arranged as a stack of multiple two dimensional memory device levels. As another non-limiting example, a three dimensional memory array may be arranged as multiple vertical columns (e.g., columns extending substantially perpendicular to the major surface of the substrate, i.e., in the y direction) with each column having multiple memory elements in each column. The columns may be arranged in a two dimensional configuration (e.g., in an x-z plane), resulting in a three dimensional arrangement of memory elements with elements arranged on multiple vertically stacked memory planes. Other configurations of memory elements in three dimensions can also constitute a three dimensional memory array.

By way of non-limiting example, in a three dimensional NAND memory array, the memory elements may be coupled together to form a NAND string within a single horizontal (e.g., x-z) memory device level. Alternatively, the memory elements may be coupled together to form a vertical NAND string that traverses across multiple horizontal memory device levels. Other three dimensional configurations can be envisioned wherein some NAND strings contain memory elements in a single memory level while other strings contain memory elements which span multiple memory levels. Three dimensional memory arrays may also be designed in a NOR configuration and in a ReRAM configuration.

Typically, in a monolithic three dimensional memory array, one or more memory device levels are formed above a single substrate. Optionally, the monolithic three dimensional memory array may also have one or more memory layers at least partially within the single substrate. As a non-limiting example, the substrate may include a semiconductor material,

such as silicon. In a monolithic three dimensional array, the layers constituting each memory device level of the array are typically formed on the layers of the underlying memory device levels of the array. However, layers of adjacent memory device levels of a monolithic three dimensional memory array may be shared or have intervening layers between memory device levels.

Two dimensional arrays may be formed separately and then packaged together to form a non-monolithic memory device having multiple layers of memory. For example, non-monolithic stacked memories can be constructed by forming memory levels on separate substrates and then stacking the memory levels atop each other. To illustrate, each of the memory device levels may have a corresponding substrate thinned or removed before stacking the memory device levels to form memory arrays. Because each of the memory device levels are initially formed over separate substrates, the resulting memory arrays are not monolithic three dimensional memory arrays. Further, multiple two dimensional memory arrays or three dimensional memory arrays (monolithic or non-monolithic) may be formed on separate chips and then packaged together to form a stacked-chip memory device.

In some implementations, the memory **104** and/or the RAM **122** is a non-volatile memory having a three dimensional (3D) memory configuration that is monolithically formed in one or more physical levels of arrays of memory cells having an active area disposed above a silicon substrate. The active area of a memory cell may be an area of the memory cell that is conductively throttled by a charge trap portion of the memory cell. The data storage device **102** and/or the host device **130** may include circuitry, such as read circuitry, write circuitry, and/or erase circuitry, as an illustrative, non-limiting example, associated with operation of the memory cells.

Associated circuitry is typically used for operation of the memory elements and for communication with the memory elements. As non-limiting examples, memory devices may have circuitry for controlling and driving memory elements to perform functions such as programming and reading. The associated circuitry may be on the same substrate as the memory elements and/or on a separate substrate. For example, a controller for memory read-write operations may be located on a separate controller chip and/or on the same substrate as the memory elements

One of skill in the art will recognize that this disclosure is not limited to the two dimensional and three dimensional structures described but cover all relevant memory structures within the spirit and scope of the disclosure as described herein and as understood by one of skill in the art.

The Abstract of the Disclosure is submitted with the understanding that it will not be used to interpret or limit the scope or meaning of the claims. In addition, in the foregoing Detailed Description, various features may be grouped together or described in a single embodiment for the purpose of streamlining the disclosure. This disclosure is not to be interpreted as reflecting an intention that the claimed embodiments require more features than are expressly recited in each claim. Rather, as the following claims reflect, inventive subject matter may be directed to less than all of the features of any of the disclosed embodiments.

The illustrations of the embodiments described herein are intended to provide a general understanding of the various embodiments. Other embodiments may be utilized and derived from the disclosure, such that structural and logical substitutions and changes may be made without departing

from the scope of the disclosure. This disclosure is intended to cover any and all subsequent adaptations or variations of various embodiments.

The above-disclosed subject matter is to be considered illustrative, and not restrictive, and the appended claims are intended to cover all such modifications, enhancements, and other embodiments, which fall within the scope of the present disclosure. Thus, to the maximum extent allowed by law, the scope of the present disclosure is to be determined by the broadest permissible interpretation of the following claims and their equivalents, and shall not be restricted or limited by the foregoing detailed description.

What is claimed is:

1. A data storage device comprising:

a non-volatile memory having a three dimensional (3D) memory configuration that is monolithically formed in one or more physical levels of arrays of memory cells having an active area disposed above a silicon substrate, the non-volatile memory including circuitry associated with operation of the memory cells, wherein the non-volatile memory comprises:

a string including a plurality of storage elements, wherein the string includes a first portion and a second portion; and

a switch coupled to the string, wherein the switch is configurable to isolate the first portion of the string from the second portion of the string based on a control signal.

2. The data storage device of claim 1, wherein the switch comprises a metal-oxide semiconductor (MOS) transistor.

3. The data storage device of claim 1, further comprising erase circuitry configured, when the first portion is isolated from the second portion, to perform a first erase operation on the second portion of the string to erase data at the second portion while maintaining data at the first portion of the string.

4. The data storage device of claim 1, wherein a first bias terminal is located at a first end of the first portion, and wherein a second bias terminal is located at a second end of the first portion.

5. The data storage device of claim 4, wherein a third bias terminal is located at a first end of the second portion, and wherein a fourth bias terminal is located at a second end of the second portion.

6. The data storage device of claim 1, further comprising a controller coupled to the non-volatile memory, wherein the controller is configured to determine whether to enable the switch to couple the first portion and the second portion or to disable the switch to decouple the first portion from the second portion.

7. The data storage device of claim 6, wherein each storage element of the plurality of storage elements corresponds to a wordline, and wherein each wordline is coupled to a different current sensor.

8. The data storage device of claim 7, wherein, during an erase operation to erase a particular wordline, a particular current sensor corresponding to the particular wordline determines an amount of current through the particular wordline, and wherein an indication of the amount of current is provided to a controller.

9. A data storage device comprising:

a non-volatile memory comprising a string including a plurality of storage elements, wherein the string includes a first portion and a second portion; and

a controller configured to generate control signals, wherein the control signals include a first control signal to cause the first portion to be coupled to the second portion and

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a second control signal to cause the first portion to be decoupled from the second portion.

10. The data storage device of claim 9, wherein the non-volatile memory further comprises a switch coupled to the string, wherein the switch is configurable to electrically couple the first portion and the second portion of the string responsive to the first control signal, and wherein the switch is configurable to isolate the first portion from the second portion of the string responsive to the second control signal.

11. The data storage device of claim 10, wherein the switch comprises a metal-oxide semiconductor (MOS) transistor.

12. The data storage device of claim 10, wherein each storage element of the plurality of storage elements corresponds to a wordline, and wherein each wordline is coupled to a different current sensor.

13. The data storage device of claim 10, wherein the non-volatile memory has a three dimensional (3D) memory configuration that is monolithically formed in one or more physical levels disposed above a silicon substrate.

14. An apparatus comprising:

a non-volatile memory having a three dimensional (3D) memory configuration that is monolithically formed in one or more physical levels above a silicon substrate, wherein the non-volatile memory comprises:

means for providing a first control signal to isolate a first portion of a string of the non-volatile memory from a second portion of the string; and

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means for providing a first erase signal to erase the second portion of the string while data is maintained at the first portion of the string.

15. The apparatus of claim 14, wherein the string includes a third portion.

16. The apparatus of claim 15, wherein the apparatus further comprises:

first means for coupling and decoupling the first portion of the string to the second portion of the string; and

second means for coupling and decoupling the second portion of the string to a third portion of the string.

17. The apparatus of claim 14, wherein the first portion is included in a first physical level of the one or more physical levels, and wherein the second portion is included in a second physical level of the one or more physical levels.

18. The apparatus of claim 14, wherein the first portion includes a first set of one or more storage elements, and wherein the second portion includes a second set of one or more storage elements.

19. The apparatus of claim 18, wherein the first set of one or more storage elements and the second set of one or more storage elements include the same number of storage elements.

20. The apparatus of claim 18, wherein the first set of one or more storage elements includes a single storage element.

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